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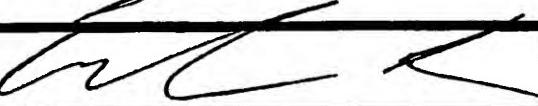
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APPLICATION NUMBER	10/747,737
FILING DATE	12/29/2003
FIRST NAMED INVENTOR	Bailey et al.
Group Art Unit	1756
Examiner Name	Unassigned
Attorney Docket Number	PA97-39D13D21

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
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EC	C66	Colbourn et al., Step and Flash Imprint Lithography: A New Approach to High-Resolution Patterning, Proc. Of SPIE, vol. 3676, 3/1/1999	
	C67	Heldari, Nanoimprint Lithography at the 6 In. Wafer Scale, J. Vac. Sci. Technol. B 18(6), pp. 3557 - 3560, 11/1/2000	
	C68	Translation of Japanese Patent 02-92603 <i>4/13/90</i>	
	C69	Translation of Japanese Patent 02-24848 <i>1/26/90</i>	
	C70	Chou et al., Ultrafast and Direct Imprint of Nanostructures in Silicon, Nature, Col. 417, (June 2002), pp. 835-837, 6/1/2002	
	C71	Chou et al., Nanoimprint Lithography, Journal of Vacuum Science Technology B 14(16), pp. 4129-4133, 11/1/1996	
	C72	Colbourn et al., Development and Advantages of Step-and-Flash Lithography, Solid State Technology, 7/1/2001	
	C73	Colbourn et al., Characterization and Modeling of Volumetric and Mechanical Properties for Step and Flash Imprint Lithography Photopolymers, Journal of Vacuum Science Technology. Vol b. 19(6), 11/1/2001	
EC	C74	Bailey et al., Step and Flash Imprint Lithography: Defect Analysis, Journal of Vacuum Science, B 19(6), pp. 2808-2810, 11/1/2001	

Examiner Signature		Date Considered	5/15/06
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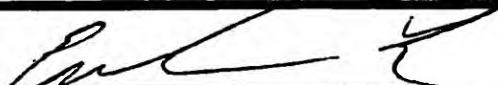
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EC	C75	Bailey et al., Step and Flash Imprint Lithography: Template Surface Treatment and Defect Analysis, Journal of Vacuum Science, B 18(6), pp. 3572-3577, 11/1/2000	
EC	C76	Schneider et al., Stripes of Partially Fluorinated Alkyl Chains: Dipolar Langmuir Monolayers 5/1/05	

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